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## Critical role of electronic states above the vacuum level in photoelectron and secondary electron emission in few-monolayer pentacene films

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Electron states above the vacuum level are known to play an important role in secondary electron processes, such as photoelectron emission and secondary electron emission where they act as “final” (or better “intermediate”) states from which an electron is emitted to the vacuum. However, despite their relevance, these states are typically not well known, nor independently investigated, mostly due to a lack of proper spectroscopic techniques. Here, we present a spectroscopy study on crystalline pentacene, used as a model system to investigate the influence of these states on secondary electron processes. Using low-energy electron (LEE) spectroscopy, we first gauge the spectrum of such states in few-monolayer pentacene films. We, subsequently, relate these states to photoelectron and secondary electron emission. Specifically, photoemission experiments (Hg lamp) show a decrease in intensity with each additional pentacene layer grown. Given an absence of increase in the ionization energy or change in the crystal structure with increasing layer count, we relate the decrease in photoemission intensity to the emergence of a band gap just above the vacuum level as observed in LEE reflectivity spectra. Second, we study the energy distribution of secondary electrons. We use electron-beam damage to cause controlled changes in the band structure, and find a clear correlation between the evolution of the LEE spectra and the distribution of secondary electrons.

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Photoemission spectroscopy techniques are among the most prevalent tools to investigate the electronic band structure of solids. Depending on the energy of the photons, different electronic bands of the material are probed. Techniques, such as x-ray photoelectron spectroscopy, extended x-ray absorption fine-structure, or near-edge x-ray absorption fine-structure target the core shells, whereas, photoemission electron microscopy (PEEM) and angle-resolved photoelectron spectroscopy among others, probe the occupied (valence) bands. The depth probed is a function of the energy of the incident photons due to the mean free path of both the photons and the ejected photoelectrons [1] and is an important consideration in the correct interpretation of the material properties from photoemission spectroscopies [2,3]. Another important factor is the electron’s initial excitation from an occupied state to an intermediate excited state above the vacuum energy before it exits the material. Although short-lived, such states are known to play an important role in the photoemission process. Unfortunately, in most photoemission studies, there is no independent information on these intermediate states. Hence, the typical approach in the interpretation of photoemission data is to assume that the electrons are excited into a free-electron-like final state, ignoring the details of the unoccupied band structure [4–7]. Still, several authors have successfully incorporated unoccupied intermediate states (confusingly often referred to as “final states” in photoemission literature) usually from theoretical calculations and very-low-energy

electron-diffraction measurements, to explain photoemission data and resolve inconsistencies in band structure mapping. Some examples include TiTe<sub>2</sub> [4], single-crystal Ni(110) [5], SiC with a graphite overlayer [8], Cu [6,7], and monolayer and bilayer graphene [9]. Also, recently, the lifetime of final states of photoelectrons has been experimentally measured in Ni(111), Ag(111), and Au(111) with values reaching ~100 as for some states [10,11].

A related phenomenon is the emission of secondary electrons (SEs). SEs generated by exposure to high-energy electrons or photons are responsible for much of the damage caused in biological and organic materials [12,13], but they are also exploited in applications, such as lithography, to deliberately cause chemical changes in an organic resist material. Nonetheless, after decades of research, our understanding of the fundamental processes regarding the generation of SEs is limited. The energy and momentum of the primary beam electrons are transferred to the electrons in the sample via multiple-scattering events, leading to a loss of information on the details of the interactions between the beam electrons and the sample electrons. The unoccupied band structure has been shown to also affect the emission of SEs [14], such as the case of graphene layers formed on SiC(0001) for which SEs show energy-dependent intensity distributions with sixfold symmetry and features ascribed to the band structure [15] or in other studies on graphite to explain the features in the SE emission spectra [16–18].

Here, we use low-energy electron microscopy (LEEM) to study the interaction of crystalline pentacene films, one to four monolayers in thickness with low-energy electrons (LEEs)

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as well as UV photons. Scattering of LEEs from the sample does not only provide real- and reciprocal-space information about the microstructure, but also yields direct information on unoccupied bands above the vacuum level and their dispersion [19,20]. Interestingly, these are exactly the states that can act as intermediates in photoemission and SE emission processes. Hence, their (un)availability directly affects the emission yield of photoelectrons and SEs.

Specifically, we connect LEEM-IV spectra (i.e., the intensity of specularly reflected low-energy electrons as a function of incident energy) to photoemission and SE spectra, performing a series of experiments within the same instrument. Our system of choice is pentacene, which can be grown and studied layer by layer in LEEM, in real-time. First, we focus on photoemission due to excitation by a standard Hg lamp ( $h\nu = 4.9\text{ eV}$ ). For a series of well-defined layer thicknesses (0–4 monolayers), we correlate photoemission intensity with LEEM-IV spectra, which contain information about the unoccupied states just above the vacuum level. Additionally, we probe the yield and energy distributions of SEs from pentacene, for a series of electron-beam energies [21]. Here, we deliberately use electron-beam damage to create chemical, structural, and electronic changes in the layers [22]. Doing this in a controlled manner allows us to correlate changes in LEEM spectra and SE energy distribution curves. Our experimental observations highlight the influence of the unoccupied states on secondary processes, such as photoemission and SE emission.

A schematic of the LEEM instrument is shown in Fig. 1(a). A beam of 15-keV electrons is decelerated to a tuneable kinetic energy of just a few eV before interaction with the sample due to a voltage bias of  $-15\text{ kV}$  from the objective lens to the sample. Reflected electrons are reaccelerated by the same electric field and guided to the detector after traveling through an aberration-correcting path including electron mirror optics, forming a real-space or diffraction image on the detector screen [23,24]. A high-pressure Hg UV lamp attached to the sample chamber provides the possibility for PEEM. All measurements are carried out in ultrahigh vacuum and at room temperature.

The pentacene layers are grown *in situ* on silicon substrates using a Knudsen-cell evaporator with line of sight to the sample. The growth dynamics of the layers is monitored in real-time both in LEEM and in PEEM as described in the literature [25–27]. At the start of sublimation, pentacene molecules are chemisorbed due to the dangling bonds on the atomically clean Si surface, leading to a decrease in photoemission intensity [27] (see Fig. S1 in the Supplemental Material Part A [28]). Afterwards, nucleation spots with higher photoemission intensity appear, which grow and merge as the sublimation continues [Fig. 1(b)]. These nucleation spots, thus, evolve into the first pentacene layer in the standing-up thin-film phase. The diffraction pattern of this layer shows that it is in a herringbone crystal structure, consistent with the literature [25]. As growth continues, subsequent layers form on top of the first layer. From the diffraction patterns of these additional layers, we find the same crystal structure as for the first layer (see Fig. S2 in the Supplemental Material Part B [28]).

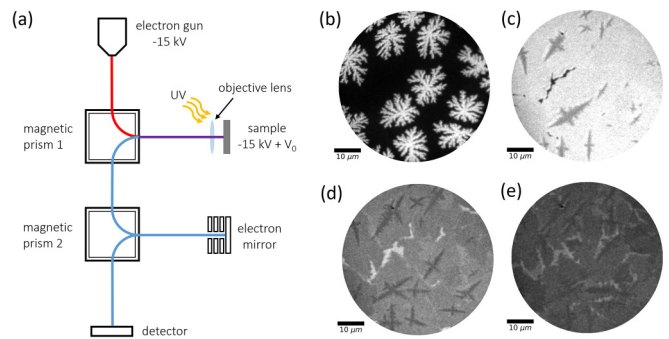


FIG. 1. (a) Schematic of the LEEM instrument. The electron beam follows the path indicated by the red line towards the sample. The electric field between the sample and the objective lens decelerates the electrons to an energy of  $eV_0$ , tuned by setting the sample voltage. The blue line shows the trajectory of the reflected electrons toward the detector. The purple line shows where the path of the incident and the reflected beams overlap. The electron mirror corrects lower-order aberrations. Magnetic prisms separate incoming and outgoing beams and allow for electron energy spectra due to their dispersive character. In PEEM, the electron gun is turned off, and the sample is irradiated with photons from a (Hg) light source. Photoemitted electrons are subsequently imaged. (b)–(e) PEEM images of various stages of pentacene layer growth: (b) initial stage of nucleation and formation of the first pentacene layer in thin-film phase, (c) the initial stage of nucleation of the second layer, which appears darker (d) the initial stage of nucleation of the third layer (e) initial stage of nucleation of the fourth layer, which creates little contrast with the third layer.

Hg PEEM images capturing various stages of growth are shown in Figs. 1(b)–1(e). The weak photoemission signal from the substrate is due to the higher ionization energy (IE) of silicon compared to the energy of the incoming photons (the IE being the minimum amount of energy required to extract a photoelectron from the sample) [29]. As is evident from Figs. 1(b)–1(e), the photoemission intensity drops for each subsequent pentacene layer after the first, even though the crystalline structure of the layers remains the same. This suggests an increase in IE with increasing layer thickness.

In the literature, the addition of consecutive layers has been reported to increase the polarization energy of a molecular layer, thereby resulting in a reduction of the ionization energy [30]. Furthermore, although ionization energies reported for the thin-film pentacene phase on  $\text{SiO}_2$  range between 4.69 and 4.93 eV for 1–20-nm films, no consistent dependence of IE on film thickness has been observed [31–36]. In fact, a decrease in IE of pentacene films on  $\text{SiO}_2$  with increasing thickness in the 1–20-nm range, accompanying broadening and splitting of the highest occupied molecular orbital band, has been reported [35]. As the PEEM intensity changes observed in Figs. 1(b)–1(e) cannot be explained by these reports, another explanation is due. This prompts us to investigate the role of unoccupied states. If the unoccupied states just above the vacuum level were to change as a function of pentacene layer thickness, the photoemission yield would also become a function of thickness. In LEEM, the energy of the incident electrons can be precisely tuned by changing the sample potential. Measuring the intensity of specularly reflected

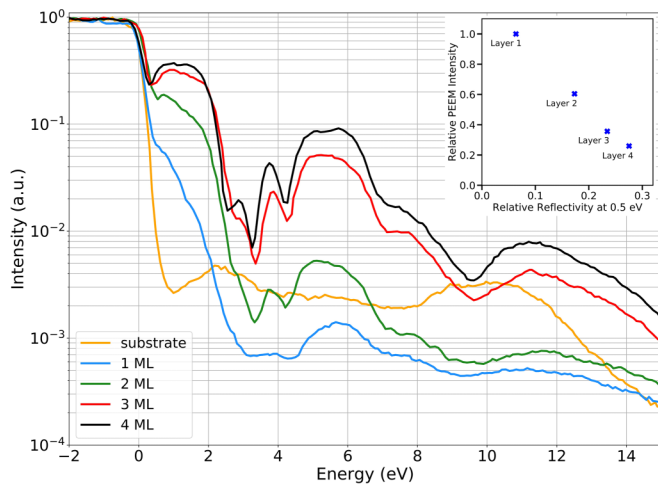


FIG. 2. (main) LEEM-IV spectra showing the evolution of reflectivity of a pentacene film across four layer counts. An energy of 0 eV corresponds to vacuum level. Negative energies indicate the electrons do not have enough kinetic energy to reach the sample, resulting in total reflection. The spectra for higher layer counts are more pronounced. Note the emergence of a band gap 0–2 eV above the vacuum level as the number of layers increases. (Inset) Relative PEEM intensity of various layer counts obtained from Fig. 1 vs the reflectivity from LEEM-IV spectra at 0.5 eV.

electrons as a function of the incident electron energy yields an intensity-vs-voltage plot, a LEEM-IV spectrum. Such LEEM-IV spectra are largely determined by the unoccupied band structure above the vacuum level [4,7,19,20,37–39]. At electron energies corresponding to a band gap (zero density of unoccupied states), incoming electrons cannot enter the sample, resulting in high reflectivity. At energies corresponding to an unoccupied state (or band) in the material, the reflectivity will be low. In the latter case, the reflectivity is determined by the coupling strength of the electron plane wave (coming from the vacuum) to the unoccupied sample state, i.e., by the Schrödinger equation. Since both key parameters [unoccupied density of states (DOS) *and* coupling probabilities] also affect photoemission, LEEM spectra are particularly helpful in understanding the intricacies of photoemission [9,40].

In Fig. 2, we show LEEM-IV spectra for pentacene films of one–four monolayers in thickness as well as for the Si substrate. Here, 0 eV corresponds to the vacuum level, and negative energies indicate insufficient kinetic energy for the incoming electrons to reach the sample (due to the negative sample bias), resulting in total reflection. The spectra in Fig. 2 are obtained from the same sample. The growth was paused after each subsequent layer, and several (two–six) LEEM-IV spectra were measured. Each of the spectra in Fig. 2 is the average of the spectra of the same layer count on the sample. The relative reflection intensity for different layer counts was consistent in all these measurements, i.e., higher layer counts resulted in higher reflection also in each of the individual measurements. The LEEM-IV spectra in Fig. 2, as well as the PEEM images in Fig. 1, were reproduced in several other samples.

The most noticeable observation in Fig. 2 is that the pentacene-related spectral features become more pronounced

with increasing layer count. This is partly due to the better crystallinity of higher layers (as evidenced by sharper diffraction peaks) resulting in sharper spectra and partly due to the diminishing effect of the substrate (which has generally lower reflectivity) on the measured reflectivity in thicker films, and partly due to the developing pentacene band structure with increasing layer thickness.

The intensity in all five LEEM-IV spectra starts to drop at the same electron energy of  $\sim 0$  eV, indicating an absence of any change in the work function (i.e., the distance between Fermi energy and vacuum level) between films of different thicknesses. This indeed confirms previous articles reporting the work function of pentacene films on SiO<sub>2</sub> and ITO to exhibit almost no change for film thicknesses from 1 to 20 nm [35,41]. The main feature in Fig. 2, however, is a marked increase in reflectivity between 0 and 2 eV as the film gets thicker. That is, a band gap appears to develop in this energy range. Moreover, given the Hg photon energy and the IEs reported for the pentacene film in the literature, the photoelectrons are expected to have “final-state” energies located within this developing band gap. Hence, for thicker films, electrons are less likely to be photoexcited, decreasing the probability of photoemission. We note that the LEEM-IV’s show a smaller degree of change in reflectivity for each consecutive layer in the 0–2-eV region; i.e., whereas the difference in reflectivity between the one-monolayer and the two-monolayer films is considerable, the relative difference between three-monolayer and four-monolayer films is much smaller. This observation is compatible with the slowing changes in PEEM intensities for thicker layers, see Figs. 1(b)–1(e). To highlight their relation, the inset of Fig. 2 plots PEEM intensity vs electron reflectivity at 0.5 eV for the different layer counts. We find a clear, negatively sloped relation. From the above, and the previous discussion on IE, we conclude that the changes observed in photoemission are directly related to changes in the unoccupied DOS just above the vacuum energy, not to changes in IE.

Next, we focus on the role of unoccupied states in secondary electron emission (resulting from impinging primary electrons). Influence of the unoccupied electronic states on the ejection of both low-energy photoelectrons and SEs can be found in the literature in the form of observed similarities between photoelectron and SE spectra [42,43]. A study of silver islands on Si(111) found Ag(111) islands to appear brighter in PEEM and also exhibit higher SE emission compared to Ag(001) islands, an observation attributed to the differences in the DOS above the vacuum level between the two [44,45]. Here, we measure and analyze LEEM-IV spectra in conjunction with SE energy spectra to provide further insight into the emission of SEs. SE energy spectra can be obtained *in situ* in LEEM, taking advantage of the energy dispersion of the magnetic prism arrays [Fig. 1(a)] [21].

In a previous study [22], we reported a gradual diminishing of LEEM-IV features as a result of continued exposure of pentacene layers to an electron beam, attributed to beam damage and loss of crystalline order in the layers. Here, we use this change as an independent tool to correlate SE emission and unoccupied states. In Fig. 3(a), we show the evolution of LEEM-IV spectra as a three-monolayer pentacene film is exposed to a beam of 10.1-eV electrons. Clear changes

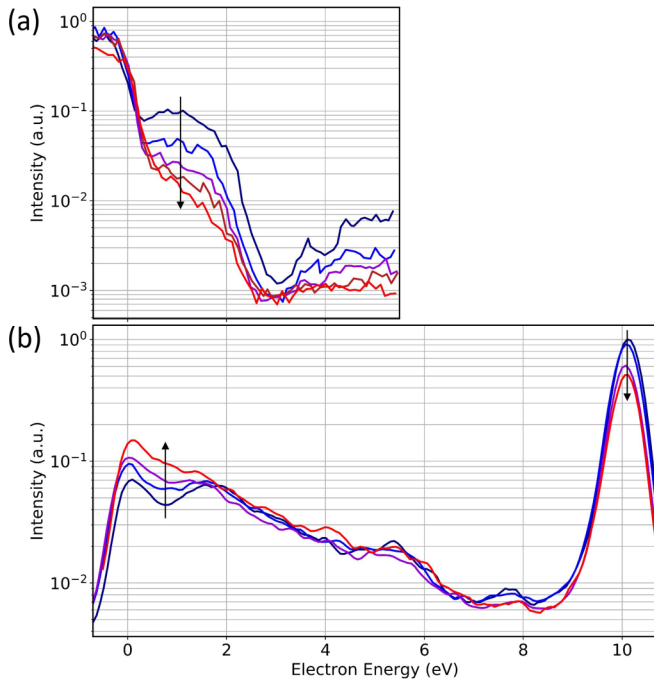


FIG. 3. Concomitant evolution of (a) LEEM-IV spectra and (b) electron energy spectra as a result of continued exposure to the electron beam (dark blue towards red). The pentacene film is three monolayers in thickness. (a) Changes in LEEM-IV spectra show the disappearance of the band gap located at 0–2 eV above the vacuum energy (0 eV). (b) The dip in secondary electron distribution gradually disappears as a result of exposure to 10.1-eV electrons. (b) is measured on the same area as (a) and in between LEEM-IV measurements. The black arrows in (a) and (b) point in the direction of increased exposure to the beam. The beam current density during measurements of spectra as well as during exposure to 10.1-eV electrons was  $6.72 \text{ pA}/\mu\text{m}^2$ . Also, an aperture with an area of  $1.15 \mu\text{m}^2$  was placed along the beam's path in order to limit the measurements to a homogeneous area.

are observed, most notably the disappearance of the band-gap-related structure around 1 eV as damage progresses. The increased level of noise in LEEM-IV spectra in Fig. 3(a) compared to Fig. 2 is due to placement of a small aperture along the beam's path, lower beam current as well as to the spectra not being averaged. In Fig. 3(b), we show a set of electron energy spectra that were measured alternately with the LEEM-IV spectra, on the same area. The strong peak at 10.1 eV corresponds to the intensity of the reflected primary electron beam, whereas the low-energy distribution (0–5 eV) corresponds to SEs (see also Supplemental Material Part C [28]). Note the clear dip in the spectrum around 1 eV. As beam damage proceeds, the electron energy spectra exhibit both a reduction in the intensity of the elastic peak at 10.1 eV and an increase in SE emission around 1 eV (figure colors: dark blue toward red). Specifically, the dip between 0 and 2 eV disappears in the later spectra (see Fig. S3 in Supplemental Material Part C [28] for more examples). This change in SE spectra, thus, happens concomitant with the diminishing of the band gap between 0 and 2 eV in Fig. 3(a) due to beam damage. These observations were reproduced in several other samples as well. We note that the measurements of the LEEM-IV

spectra themselves (taken in-between measurements of the electron energy spectra) are expected to cause only minimal damage. This is due to the negligible damage cross section of pentacene films for electrons of energies up to  $\sim 5.5 \text{ eV}$  [22], i.e., the energy up to which the LEEM-IV spectra in Fig. 3(a) were obtained. Hence, the changes in Fig. 3(b) are only caused by exposure to electrons of fixed energy (10.1 eV). The exposure period varied between  $\sim 1 \text{ min}$  for the exposure between the first two electron energy spectra, and  $\sim 10 \text{ min}$  between the last two spectra, indicating a faster rate of change in the electronic properties of the sample at the beginning, i.e., when the sample is pristine.

Our interpretation is that the states above the vacuum level play a key role in the SE spectra observed. Specifically, the band gap at energies 0–2 eV above the vacuum energy suppresses the ejection of SEs with those energies due to a lower density of available (intermediate) states. This results in the appearance of a dip in the energy distribution of SEs for pristine pentacene layers. The disappearance of a well-defined band gap – as a result of chemical and electronic changes in the sample due to beam exposure – results in a higher density of available states for the SEs, hence, creating a pathway for emission of SEs. This is similar to the case of photoemission discussed above. Note that previous ultraviolet photoelectron spectroscopy measurements on pentacene films on  $\text{SiO}_2$  and ITO with the same herringbonelike structure, have also reported a dip in the energy distribution of SEs. Interestingly, such a pattern was not observed in pentacene films on highly oriented pyrolytic graphite where the molecules adopt a recumbent orientation [35,41]. This marked difference led to the attribution of the SE pattern to film structure-dependent unoccupied DOS, similar to what is discussed here.

Summarizing, we have highlighted the importance of the unoccupied band structure in the interpretation of data from photoemission spectroscopies and secondary electron measurements. For this, we have combined and compared direct measurements of LEEM-IV spectra above the vacuum level in thin pentacene layers, performed by LEEM, with photoemission and secondary electron energy distribution measurements. We find that knowledge of the DOS above the vacuum energy is essential for a detailed analysis of photoemission measurements. Our data also indicate that the energy distribution and yield of secondary electrons are modulated by unoccupied states above the vacuum level. Hence, this material property should also be taken into account to understand and model generation and ejection of secondary electrons. In conclusion, we have demonstrated that LEEM-IV spectra, which provide direct information on the unoccupied states, form an essential piece of information in the analysis of both photoemission and secondary electron emission processes.

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The authors declare no competing interests.

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